In re Appln. of CHAWLA et al. Application No. 10/008,489

## REMARKS

In their response of August 16, 2004, and in a secondary argument in support of patentability, it was stated by applicants that "the cited prior art is directed to hybrid adhesive systems, including both cationic and free radical systems." However, it is understood that the thiol-ene polymerization system disclosed in the cited prior art proceeds via a free radical mechanism.

## Conclusion

The application is considered in good and proper form for allowance, and the Examiner is respectfully requested to pass this application to issue. If, in the opinion of the Examiner, a telephone conference would expedite the prosecution of the subject application, the Examiner is invited to call the undersigned attorney.

Respectfully submitted,

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